

DT15 Rec'd PCT/PTO 24 JAN 2005

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:

Daniel MEISEL et al.

International Appln: PCT/EP2003/007819

U.S. Application No.: Not Yet Assigned

For: METHOD FOR THE PRODUCTION
OF PHOTORESIST STRUCTURES

Art Unit: Not Yet Assigned

Examiner: Not Yet Assigned

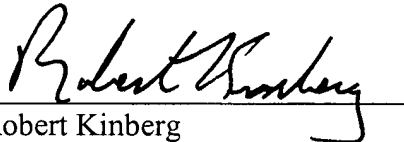
Confirmation No.: Not Yet Assigned

Atty. Docket No.: 31775-210910 RKCustomer No.: **26694****Submission of Formal Drawings**Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Submitted herewith are two (2) sheets of formal drawings containing Figs. 1-2.

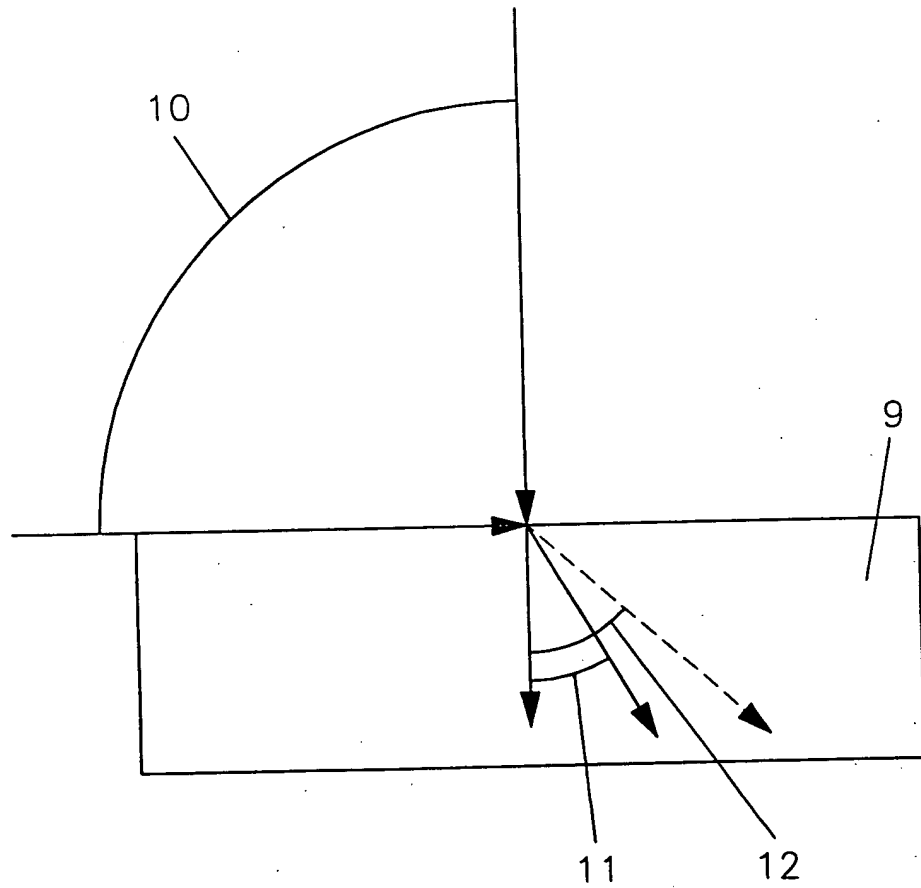
Respectfully submitted,

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Fig. 1



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Fig. 2

